Contents

	Controlling the Size and Position in Nanoscale				
	2.1	Introduction			
	2.2	Fabrication of Nano-structure Using Optical Near-I	Field		
		2.2.1 Photo Chemical Vapor Deposition			
		2.2.2 Near-Field Optical Chemical Vapor Deposit	ion		
		2.2.3 Regulating the Size and Position of Deposit	ed		
		Nanoparticles			
		2.2.4 Observation of Size-Dependent Resonance	of		
		Near-Field Coupling Between Deposited Zr	n Dot		
		and Probe Apex During NFO-CVD			
	Refe	ferences			
	Self-assembled Size Regulation and Its Alignment				
	Self	f-assembled Size Regulation and Its Alignment			
	Self 3.1				
		Introduction			
	3.1	Introduction			
	3.1	Introduction			
	3.1	Introduction			
	3.1 3.2	Introduction Size-, Position-, and Separation-Controlled One-Dimensional Alignment of Nanoparticles Using an Optical Near Field Self-assembly of Size- and Position-Controlled Ult			
	3.13.23.3	Introduction Size-, Position-, and Separation-Controlled One-Dimensional Alignment of Nanoparticles Using an Optical Near Field Self-assembly of Size- and Position-Controlled Ult High-Resolution Capability of Optical Near-Field Imprint Lithography	ra-long		
	3.13.23.3	Introduction Size-, Position-, and Separation-Controlled One-Dimensional Alignment of Nanoparticles Using an Optical Near Field Self-assembly of Size- and Position-Controlled Ult High-Resolution Capability of Optical Near-Field Imprint Lithography	ra-long		
•	3.1 3.2 3.3 3.4	Introduction Size-, Position-, and Separation-Controlled One-Dimensional Alignment of Nanoparticles Using an Optical Near Field Self-assembly of Size- and Position-Controlled Ult High-Resolution Capability of Optical Near-Field Imprint Lithography Self-assembly of ZnO QDs	ra-long		

DEUTSCHE NATIONAL BIBLIOTHEK viii Contents

4	Phonon-Assisted Process				
	4.1	Dresse	ed-Photon and Phonon	67	
	4.2	Angsti	rom Scale Flattening Process	68	
		4.2.1	Phonon-Assisted Optical Near-Field Etching	69	
		4.2.2	In situ Real-Time Monitoring of Changes in the		
			Surface Roughness During Phonon-Assisted		
			Optical Near-Field Etching	72	
		4.2.3	Self-organized Near-Field Etching of the		
		~	Sidewalls of Glass Corrugations	79	
		4.2.4	Repairing Nanoscale Scratched Grooves		
			on Polycrystalline Ceramics Using Optical		
			Near-Field Assisted Sputtering	85	
	4.3	elective Patterning	89		
		4.3.1	Production of Size-Controlled Si Nanocrystals		
			Using Self-organized Optical Near-Field		
			Chemical Etching	89	
		4.3.2	Site-Selective Deposition of Gold Nanoparticles		
			Using Non-adiabatic Reaction Induced by Optical		
			Near Fields	94	
	4.4	Increased Spatial Homogeneity			
	4.5	·			
			ed Process	107	
	Refe	erences		114	
5	Som	a Pame	arks and Outlook	117	
	5.1	rks	117		
	3.1	5.1.1	Photolithography	117	
		5.1.2	Near-Field Etching	118	
		5.1.3	<u> </u>	118	
		5.1.4	Nanophotonic Energy Conversion	118	
	5.2		nary	119	
			iary	120	
In	dex			121	